

Electronic Acknowledgement Receipt

EFS ID:	1324961
Application Number:	10812602
International Application Number:	
Confirmation Number:	3173
Title of Invention:	Wafer, exposure mask, method of detecting mark and method of exposure
First Named Inventor/Applicant Name:	Shinichiro Nohdo
Customer Number:	26263
Filer:	David Richard Metzger/Barbara Hannon
Filer Authorized By:	David Richard Metzger
Attorney Docket Number:	9792909-5846
Receipt Date:	20-NOV-2006
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Application Type:	Utility

Payment information:

Submitted with Payment	no
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File Listing:

Document Number	Document Description	File Name	File Size(Bytes)	Multi Part /.zip	Pages (if appl.)
1	Response to Election / Restriction Filed	Sony_5846_Resp_Restr.pdf	28588	no	1

Warnings:

Information:	
Total Files Size (in bytes):	28588
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<p><u>New Applications Under 35 U.S.C. 111</u> If a new application is being filed and the application includes the necessary components for a filing date (see 37 CFR 1.53(b)-(d) and MPEP 506), a Filing Receipt (37 CFR 1.54) will be issued in due course and the date shown on this Acknowledgement Receipt will establish the filing date of the application.</p>	
<p><u>National Stage of an International Application under 35 U.S.C. 371</u> If a timely submission to enter the national stage of an international application is compliant with the conditions of 35 U.S.C. 371 and other applicable requirements a Form PCT/DO/EO/903 indicating acceptance of the application as a national stage submission under 35 U.S.C. 371 will be issued in addition to the Filing Receipt, in due course.</p>	